Supporting information

Enhancing the inter-grain connectivity of CVD grown graphene

by promoter caps

Ya-Ping Hsieh^{a*}, Yi-Jing Chiu^a, and Mario Hofmann^b

 ^a Graduate of Institute of Opto-Mechatronics, National Chung Cheng University, 168, University Rd., Min-Hsiung, Chia-Yi, 62102, Taiwan
^b Department of Material Science and Engineering, National Cheng Kung University,

Tainan, 62102, Taiwan

E-mail: yphsieh@ccu.edu.tw

1. Optical Micrographs of oxidation tests

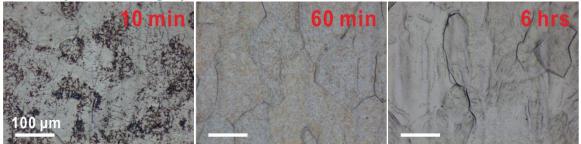


Figure S1: OM images of oxidized graphene for 10 min, 60 min and 6 hrs.

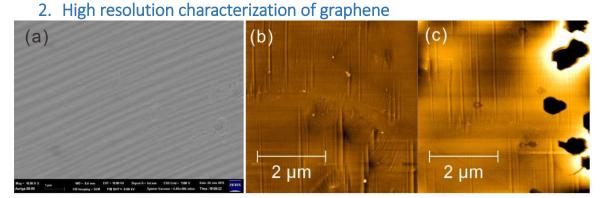


Figure S2: (a) SEM image<u>of grown graphene</u>, (b) AFM image of grown graphene, (c) identical area to (b) after FIFE

1

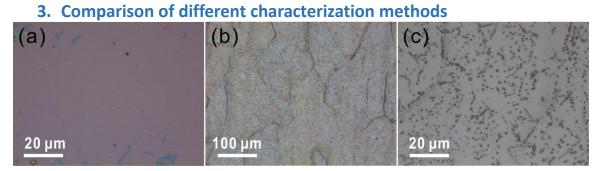


Figure S3: Characterization after 60 mins of growth (a) OM transferred, (b) air oxidized (c) APS etching.

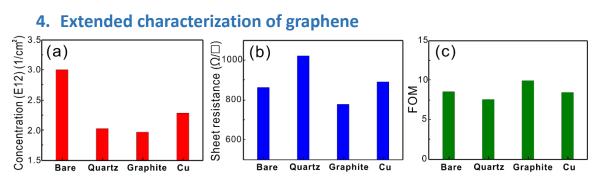


Figure S4: (a)Carrier concentration, (b) sheet resistance and its (c)figure of merit as transparent optical conductor of the as grown graphene under different capping materials.

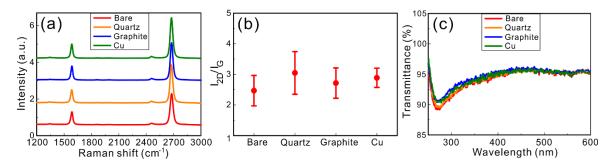


Figure S5: Raman spectrum and $I_{2D}/I_G > 2.5$ suggesting uniform single layer of graphene were synthesized with graphite promoter.

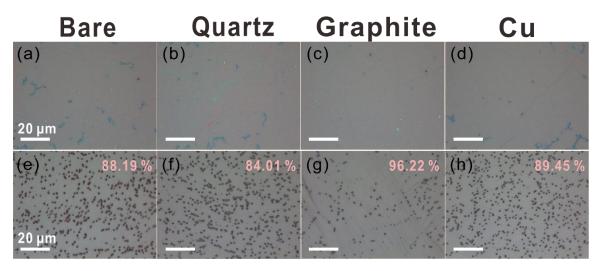
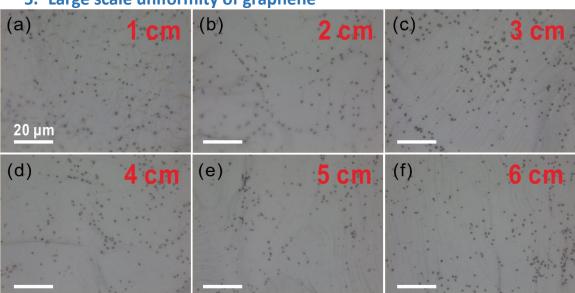


Figure S6: comparison of various cap (quartz, graphite and copper) and no cap (bare), (a-d) OM images after transfer on SiO_x showing uniformity of graphene and (e-h) after APS etching on graphene/Cu.



5. Large scale uniformity of graphene

Figure S7: APS etching along x-direction after graphene growth with graphite promoter